

Search Report

EIC 1700

STIC Database Tracking Number: 240339

To: MICHAEL BERNSHTEYN

Location: REM-10D25

Art Unit: 1796

Tuesday, October 16, 2007

Case Serial Number: 10/554242

From: MEI HUANG

Location: EIC1700

REM-4B28 / REM-4B31

Phone: (571)272-3952

mei.huang@uspto.gov

Search Notes

Examiner BERNSHTEYN:

Please feel free to contact me if you have any questions or if you would like to refine the search query. Thank you for using STIC services!

Regards,
Mei



OCT 16 2007

Pat. & T.M. Office

SEARCH REQUEST FORM

Scientific and Technical Information Center

Requester's Full Name: Michael Bernshkeyn Examiner #: 81515 Date: 10/18/07
Art Unit: 1796 Phone Number 30 278-2411 Serial Number: 10/554,242
Mail Box and Bldg/Room Location: Box 10 D 25 Results Format Preferred (circle): PAPER DISK E-MAIL

If more than one search is submitted, please prioritize searches in order of need.

Please provide a detailed statement of the search topic, and describe as specifically as possible the subject matter to be searched. Include the elected species or structures, keywords, synonyms, acronyms, and registry numbers, and combine with the concept or utility of the invention. Define any terms that may have a special meaning. Give examples or relevant citations, authors, etc, if known. Please attach a copy of the cover sheet, pertinent claims, and abstract.

Title of Invention: Process for production of living-radical polymers
Inventors (please provide full names): Shigeru Yamago, Gunichi Yoshida,
Takashi Kameshima

Earliest Priority Filing Date: 04/25/2003

For Sequence Searches Only Please include all pertinent information (parent, child, divisional, or issued patent numbers) along with the appropriate serial number.

Please, try to find a polymer initiator according claims 1-3, comprising an organotellurium compound of formula (1), ditelluride of formula (2) and azo initiator.

Thank you

M. Bernshkeyn

STAFF USE ONLY

Searcher: MH
Searcher Phone #: _____
Searcher Location: _____
Date Searcher Picked Up: 10/16/07
Date Completed: _____
Searcher Prep & Review Time: _____
Clerical Prep Time: _____
Online Time: _____

Type of Search

NA Sequence (#) _____
AA Sequence (#) _____
Structure (#) 3
Bibliographic _____
Litigation _____
Fulltext _____
Patent Family _____
Other _____

Vendors and cost where applicable

STN ☒ _____
Dialog _____
Questel/Orbit _____
Dr.Link _____
Lexis/Nexis _____
Sequence Systems _____
WWW/Internet _____
Other (specify) _____



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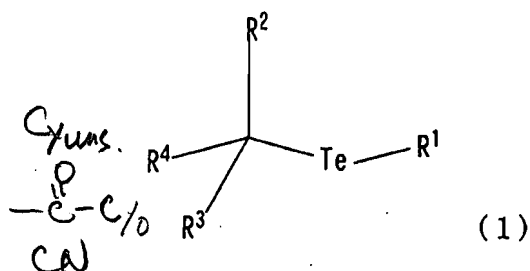
Bib Data Sheet

CONFIRMATION NO. 6569

SERIAL NUMBER	FILING OR 371(c) DATE	CLASS	GROUP ART UNIT	ATTORNEY DOCKET NO.	
10/554,242	10/25/2005	526	1713	2005-1665A	
APPLICANTS Shigeru Yamago, Ichijoji-sagarimatsu cho, JAPAN; Junichi Yoshida, Higashikorimotomachi, JAPAN; Takashi Kameshima, Kagasuno, JAPAN;					
** CONTINUING DATA ***** This application is a 371 of PCT/JP04/05989 04/26/2004					
** FOREIGN APPLICATIONS ***** JAPAN 2003-121223 04/25/2003					
IF REQUIRED, FOREIGN FILING LICENSE GRANTED ** 05/30/2006					
Foreign Priority claimed <input checked="" type="checkbox"/> yes <input type="checkbox"/> no 35 USC 119 (a-d) conditions <input checked="" type="checkbox"/> yes <input type="checkbox"/> no <input type="checkbox"/> Met after met Verified and Acknowledged <i>M. Bernshteyn MB</i> Examiner's Signature Initials		STATE OR COUNTRY JAPAN	SHEETS DRAWING 0	TOTAL CLAIMS 3	INDEPENDENT CLAIMS 3
ADDRESS 513					
TITLE Process for production of living-radical polymers and polymers					
FILING FEE RECEIVED 900	FEES: Authority has been given in Paper No. _____ to charge/credit DEPOSIT ACCOUNT No. _____ for following:		<input type="checkbox"/> All Fees <input type="checkbox"/> 1.16 Fees (Filing) <input type="checkbox"/> 1.17 Fees (Processing Ext. of time) <input type="checkbox"/> 1.18 Fees (Issue) <input type="checkbox"/> Other _____ <input type="checkbox"/> Credit		

Amendments to the Claims

1. (Currently amended) A process for producing a living radical polymer which comprises polymerizing a vinyl monomer in the presence of an organotellurium compound represented by the formula (1), an azo type polymerization initiator and a ditelluride compound represented by the formula (2)

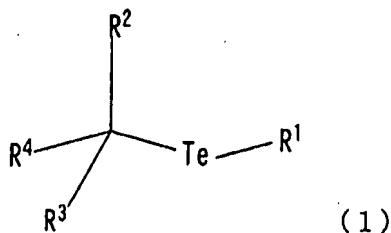


wherein R^1 is $\text{C}_1\text{-C}_8$ alkyl, aryl, substituted aryl or an aromatic heterocyclic group, R^2 and R^3 are each a hydrogen atom or $\text{C}_1\text{-C}_8$ alkyl, and R^4 is aryl, substituted aryl, an aromatic heterocyclic group, acyl, oxycarbonyl or cyano,



wherein R^1 is the same as above, to obtain a living radical polymer having a molecular weight distribution of 1.05 to 1.50.

2. (Currently amended) A living radical polymer having a molecular weight distribution of 1.05 to 1.50 produced by polymerizing a vinyl monomer in the presence of an organotellurium compound represented by the formula (1), an azo type polymerization initiator and a ditelluride compound represented by the formula (2)

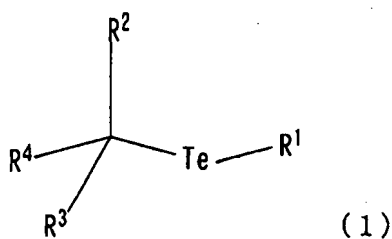


wherein R^1 is C_1 - C_8 alkyl, aryl, substituted aryl or an aromatic heterocyclic group, R^2 and R^3 are each a hydrogen atom or C_1 - C_8 alkyl, and R^4 is aryl, substituted aryl, an aromatic heterocyclic group, acyl, oxycarbonyl or cyano,

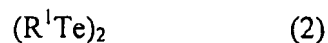


wherein R^1 is the same as above.

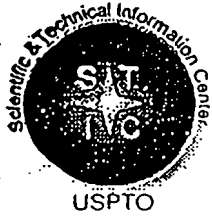
3. (Previously presented) A mixture of an organotellurium compound represented by the formula (1), an azo type polymerization initiator and a ditelluride compound represented by the formula (2)



wherein R^1 is C_1 - C_8 alkyl, aryl, substituted aryl or an aromatic heterocyclic group, R^2 and R^3 are each a hydrogen atom or C_1 - C_8 alkyl, and R^4 is aryl, substituted aryl, an aromatic heterocyclic group, acyl, oxycarbonyl or cyano,



wherein R^1 is the same as above.



STIC Search Results Feedback Form

EIC17000

Questions about the scope or the results of the search? Contact *the EIC searcher* or contact:

Kathleen Fuller, EIC 1700 Team Leader
571/272-2505 REMSEN 4B28

Voluntary Results Feedback Form

- I am an examiner in Workgroup: Example: 1713
➤ Relevant prior art found, search results used as follows:

- ☐ 102 rejection
- ☐ 103 rejection
- ☐ Cited as being of interest.
- ☐ Helped examiner better understand the invention.
- ☐ Helped examiner better understand the state of the art in their technology.

Types of relevant prior art found:

- ☐ Foreign Patent(s)
- ☐ Non-Patent Literature
(journal articles, conference proceedings, new product announcements etc.)

➤ Relevant prior art not found:

- ☐ Results verified the lack of relevant prior art (helped determine patentability).
- ☐ Results were not useful in determining patentability or understanding the invention.

Comments:

Drop off or send completed forms to EIC1700 REMSEN 4B28

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STRUCTURE FILE UPDATES: 15 OCT 2007 HIGHEST RN 950725-14-1

DICTIONARY FILE UPDATES: 15 OCT 2007 HIGHEST RN 950725-14-1

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<http://www.cas.org/support/stngen/stndoc/properties.html>

=> d que stat l13

L4 STR

Te~C

1 2

NODE ATTRIBUTES:

NSPEC IS RC AT 2

DEFAULT MLEVEL IS ATOM

DEFAULT ECLEVEL IS LIMITED

GRAPH ATTRIBUTES:

RING(S) ARE ISOLATED OR EMBEDDED

NUMBER OF NODES IS 2

STEREO ATTRIBUTES: NONE

L6 SCR 2040

L8 8193 SEA FILE=REGISTRY SSS FUL L4 NOT L6

L11 STR

G2~G1~Te~G3
4 3 1 2

CH2 @5

CH~Ak
@6 7

10
Ak
}
C~Ak
@8 9

Cy @11 14
O
|||
C~C
@12 13

17
O
|||
C~O
@15 16

Ak @18 Cy @19

VAR G1=5/6/8

MHuang REM4B31 571-272-3952

10/16/2007

VAR G2=11/12/15/CN

VAR G3=18/19

NODE ATTRIBUTES:

DEFAULT MLEVEL IS ATOM

GGCAT IS SAT AT 7

GGCAT IS SAT AT 9

GGCAT IS SAT AT 10

GGCAT IS UNS AT 11

GGCAT IS SAT AT 18

GGCAT IS UNS AT 19

DEFAULT ECLEVEL IS LIMITED

ECOUNT IS M1-X8 C AT 7

ECOUNT IS M1-X8 C AT 9

ECOUNT IS M1-X8 C AT 10

ECOUNT IS M1-X8 C AT 18

GRAPH ATTRIBUTES:

RING(S) ARE ISOLATED OR EMBEDDED

NUMBER OF NODES IS 19

STEREO ATTRIBUTES: NONE

L13 244 SEA FILE=REGISTRY SUB=L8 SSS FUL L11

100.0% PROCESSED 8193 ITERATIONS

244 ANSWERS

SEARCH TIME: 00.00.01

=> d que stat l16

L4 STR

Te~C

1 2

NODE ATTRIBUTES:

NSPEC IS RC AT 2

DEFAULT MLEVEL IS ATOM

DEFAULT ECLEVEL IS LIMITED

GRAPH ATTRIBUTES:

RING(S) ARE ISOLATED OR EMBEDDED

NUMBER OF NODES IS 2

STEREO ATTRIBUTES: NONE

L6 SCR 2040

L8 8193 SEA FILE=REGISTRY SSS FUL L4 NOT L6

L10 STR

G1~Te~Te~G1 Ak@5 Cy@6

4 3 1 2

VAR G1=5/6

NODE ATTRIBUTES:

DEFAULT MLEVEL IS ATOM

GGCAT IS SAT AT 5

GGCAT IS UNS AT 6

DEFAULT ECLEVEL IS LIMITED

ECOUNT IS M1-X8 C AT 5

GRAPH ATTRIBUTES:

RING(S) ARE ISOLATED OR EMBEDDED
NUMBER OF NODES IS 6

STEREO ATTRIBUTES: NONE

L16 445 SEA FILE=REGISTRY SUB=L8 SSS FUL L10

100.0% PROCESSED 736 ITERATIONS

445 ANSWERS

SEARCH TIME: 00.00.01

=> d his

(FILE 'HOME' ENTERED AT 14:48:18 ON 16 OCT 2007)

FILE 'HCAPLUS' ENTERED AT 14:48:27 ON 16 OCT 2007

E US20060199927/PN

L1 1 S E3
SEL RN

FILE 'REGISTRY' ENTERED AT 14:48:53 ON 16 OCT 2007

L2 33 S E1-33
L3 6 S L2 AND TE/ELS

FILE 'LREGISTRY' ENTERED AT 15:02:03 ON 16 OCT 2007

L4 STR

FILE 'REGISTRY' ENTERED AT 15:03:33 ON 16 OCT 2007

L5 50 S L4
L6 SCR 2040
L7 50 S L4 NOT L6
L8 8193 S L4 NOT L6 FUL
L9 5 S L2 AND L8
SAV L8 BER242/A

FILE 'LREGISTRY' ENTERED AT 15:04:45 ON 16 OCT 2007

L10 STR L4
L11 STR L4

FILE 'REGISTRY' ENTERED AT 15:20:30 ON 16 OCT 2007

L12 15 S L11 SSS SAM SUB=L8
L13 244 S L11 SSS FUL SUB=L8
L14 3 S L2 AND L13
SAV L13 BER242S1/A
L15 24 S L10 SSS SAM SUB=L8
L16 445 S L10 SSS FUL SUB=L8
L17 2 S L2 AND L16
SAV L16 BER242S2/A

FILE 'HCAPLUS' ENTERED AT 15:23:45 ON 16 OCT 2007

L18 183 S L13
L19 1141 S L16
L20 58 S L18 AND L19
L21 16 S L13(L) CAT/RL
L22 27 S L16(L) CAT/RL
L23 5 S L21 AND L22
L24 QUE CATALYST
L25 14 S L20 AND L24
L26 QUE INITIAT? OR INIT#
L27 7 S L20 AND L26
L28 15 S L25 OR L27

L29 10 S L28 NOT L23

=> fil hcap
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FILE COVERS 1907 - 16 Oct 2007 VOL 147 ISS 17
FILE LAST UPDATED: 15 Oct 2007 (20071015/ED)

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=> d l23 ibib abs hitstr hitind 1-5

L23 ANSWER 1 OF 5 HCAPLUS COPYRIGHT 2007 ACS on STN
ACCESSION NUMBER: 2006:888365 HCAPLUS
DOCUMENT NUMBER: 145:272431
TITLE: Manufacture of aqueous polymer solutions using organotellurium compounds
INVENTOR(S): Okubo, Masayoshi; Kameshima, Takashi; Kono, Kazuhiro; Makoto, Takeshi
PATENT ASSIGNEE(S): Kobe University, Japan; Otsuka Chemical Co., Ltd.
SOURCE: Jpn. Kokai Tokkyo Koho, 17pp.
CODEN: JKXXAF
DOCUMENT TYPE: Patent
LANGUAGE: Japanese
FAMILY ACC. NUM. COUNT: 1
PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
JP 2006225524	A	20060831	JP 2005-41321	20050217
PRIORITY APPLN. INFO.:				20050217

OTHER SOURCE(S): MARPAT 145:272431
AB Vinyl monomers are polymerized in aqueous media by using R1TeCR2R3R4 [R1 = C1-8 alkyl, (un)substituted aryl, aromatic heterocyclic group; R2, R3 =

H, C1-8 alkyl; R4 = (un)substituted aryl, aromatic heterocyclic group, acyl, oxycarbonyl, cyano] and surfactants and/or dispersing agents to give the aqueous solns. The aqueous solns. are used as macroinitiators in polymerization of vinyl monomers. Thus, Me methacrylate was polymerized at 60° for 24 h in H2O in the presence of ethyl-2-methyl-2-butyltellanyl propionate, di-Bu ditelluride, AIBN, and Na dodecylsulfonate to give an aqueous PMMA emulsion with conversion 77%, Mn 20,900 and Mw/Mn 1.36.

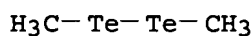
IT 20334-43-4P, Dimethyl ditelluride 474094-06-9P
658058-35-6P

RL: CAT (Catalyst use); IMF (Industrial manufacture); PREP
(Preparation); USES (Uses)

(manufacture of aqueous polymer solns. using organotellurium compds.)

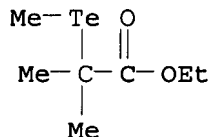
RN 20334-43-4 HCAPLUS

CN Ditelluride, dimethyl (9CI) (CA INDEX NAME)



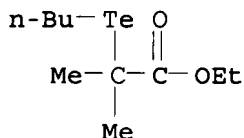
RN 474094-06-9 HCAPLUS

CN Propanoic acid, 2-methyl-2-(methyltelluro)-, ethyl ester (CA INDEX NAME)



RN 658058-35-6 HCAPLUS

CN Propanoic acid, 2-(butyltelluro)-2-methyl-, ethyl ester (CA INDEX NAME)



CC 37-3 (Plastics Manufacture and Processing)

IT 20334-43-4P, Dimethyl ditelluride 474094-06-9P
658058-35-6P

RL: CAT (Catalyst use); IMF (Industrial manufacture); PREP
(Preparation); USES (Uses)

(manufacture of aqueous polymer solns. using organotellurium compds.)

L23 ANSWER 2 OF 5 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER: 2005:428591 HCAPLUS

DOCUMENT NUMBER: 142:454333

TITLE: Radiation-sensitive chemically amplified
positive-working resists

INVENTOR(S): Nishimura, Isao; Kobayashi, Eiichi; Seyano,
Akimasa; Wang, Yong

PATENT ASSIGNEE(S): JSR Ltd., Japan

SOURCE: Jpn. Kokai Tokkyo Koho, 44 pp.

DOCUMENT TYPE: CODEN: JKXXAF
 LANGUAGE: Patent
 FAMILY ACC. NUM. COUNT: Japanese 1
 PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
JP 2005128049	A	20050519	JP 2003-360291	20031021
PRIORITY APPLN. INFO.:			JP 2003-360291	20031021

OTHER SOURCE(S): MARPAT 142:454333

AB The resists comprise alkali-insol. polymers having acid-labile groups increasing solubility in alkaline solns. upon contact with acids, and radiation-sensitive acid generators, wherein the polymers are prepared by using $RbC(Rc)(Rd)TeRa$ [$Ra = C1-8$ alkyl, (substituted) aryl, atom. heterocycle; $Rb, Rc = H, C1-8$ alkyl; $Rd = (substituted)$ aryl, aromatic heterocycle, acyl, etc.], and optionally ditellurides $(RaTe)_2$ as radical living polymerization initiators. In the polymerization, radical polymerization

initiators may also be employed. The polymers has narrow mol.-weight distribution peaks with small lot-to-lot fluctuation and resultant resists show high transparency and sensitivity for far UV, x rays, and electron rays, and high dry etching resistance, and provide fine patterns with good profile.

IT 20334-43-4P, Dimethyl ditelluride 77129-69-2P,
 Di(butyl) ditelluride 474094-06-9P 658058-35-6P

RL: CAT (Catalyst use); IMF (Industrial manufacture); PREP (Preparation); USES (Uses)

(radical living polymerization initiator, for preparing polymer; radiation-sensitive pos.-working resist containing polymer prepared by using radical living polymerization)

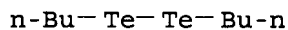
RN 20334-43-4 HCAPLUS

CN Ditelluride, dimethyl (9CI) (CA INDEX NAME)



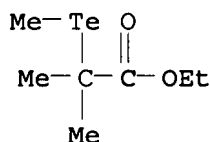
RN 77129-69-2 HCAPLUS

CN Ditelluride, dibutyl (CA INDEX NAME)



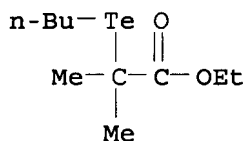
RN 474094-06-9 HCAPLUS

CN Propanoic acid, 2-methyl-2-(methyltelluro)-, ethyl ester (CA INDEX NAME)



RN 658058-35-6 HCAPLUS

CN Propanoic acid, 2-(butyltelluro)-2-methyl-, ethyl ester (CA INDEX NAME)



IC ICM G03F007-039

ICS C08F004-72; H01L021-027; C08F020-00

CC 74-5 (Radiation Chemistry, Photochemistry, and Photographic and Other Reprographic Processes)

Section cross-reference(s): 35, 38

IT 20334-43-4P, Dimethyl ditelluride 77129-69-2P,

Di(butyl) ditelluride 474094-06-9P 658058-35-6P

RL: CAT (Catalyst use); IMF (Industrial manufacture); PREP (Preparation); USES (Uses)

(radical living polymerization initiator, for preparing polymer; radiation-sensitive pos.-working resist containing polymer prepared by using radical living polymerization)

L23 ANSWER 3 OF 5 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER: 2005:428239 HCAPLUS

DOCUMENT NUMBER: 142:464450

TITLE: Acid-dissociating group-containing acrylic polymers with narrow molecular weight distribution and their manufacture

INVENTOR(S): Nishimura, Isao; Wang, Yong; Kameshima, Takashi

PATENT ASSIGNEE(S): JSR Ltd., Japan; Otsuka Chemical Co., Ltd.

SOURCE: Jpn. Kokai Tokkyo Koho, 37 pp.

CODEN: JKXXAF

DOCUMENT TYPE: Patent

LANGUAGE: Japanese

FAMILY ACC. NUM. COUNT: 1

PATENT INFORMATION:

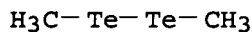
PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
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JP 2005126459	A	20050519	JP 2003-360290	20031021
PRIORITY APPLN. INFO.:				20031021

OTHER SOURCE(S): MARPAT 142:464450

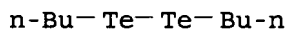
AB The polymers, especially useful for lithog., are manufactured in the presence

(1) R1TeCR2R3R4 [I; R1 = C1-8 alkyl, (un)substituted aryl, aromatic heterocyclic; R2,3 = H, C1-8 alkyl; R4 = (un)substituted aryl, aromatic heterocyclic, acyl, oxycarbonyl, cyano] or (2) mixts. of ≥ 1 compds. selected from I, radical polymerization initiators, and (R5Te)2 (R5 = same as R1). Thus, 3.5 mmol 2-methyl-2-propenoic acid hexahydro-2-oxo-3,5-methano-2H-cyclopenta[b]furan-6-yl ester, 1.5 mmol 2-methyl-2-propenoic acid 3-hydroxytricyclo[3.3.1.1^{3,7}]dec-1-yl ester, and 5 mmol 2-methyl-2-propenoic acid 2-methyltricyclo[3.3.1.1^{3,7}]dec-2-yl ester were polymerized in the presence of Et 2-methyl-2-(butyltelluro)propanoate (0.2 mmol), dibutylditelluride (0.10 mmol), and MAIB (0.10 mmol) to give a copolymer (yield 85%) showing Mw 10000, Mw/Mn 1.24, good solubility to propylene glycol monomethyl ether acetate, and decreased Mw fluctuation.

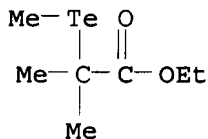
IT 20334-43-4P, Dimethylditelluride 77129-69-2P,
Dibutylditelluride 474094-06-9P 658058-35-6P
RL: CAT (Catalyst use); IMF (Industrial manufacture); PREP
(Preparation); USES (Uses)
(living polymerization initiator; acid-dissociating group-containing acrylic polymers with narrow mol. weight distribution)
RN 20334-43-4 HCAPLUS
CN Ditelluride, dimethyl (9CI) (CA INDEX NAME)



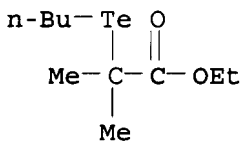
RN 77129-69-2 HCAPLUS
CN Ditelluride, dibutyl (CA INDEX NAME)



RN 474094-06-9 HCAPLUS
CN Propanoic acid, 2-methyl-2-(methyltelluro)-, ethyl ester (CA INDEX NAME)



RN 658058-35-6 HCAPLUS
CN Propanoic acid, 2-(butyltelluro)-2-methyl-, ethyl ester (CA INDEX NAME)



IC ICM C08F004-00
ICS C08F020-10; G03F007-033; G03F007-039; C07C395-00

CC 37-3 (Plastics Manufacture and Processing)
 Section cross-reference(s): 74
 IT 20334-43-4P, Dimethylditelluride 77129-69-2P,
 Dibutylditelluride 474094-06-9P 658058-35-6P
 RL: CAT (Catalyst use); IMF (Industrial manufacture); PREP
 (Preparation); USES (Uses)
 (living polymerization initiator; acid-dissociating group-containing acrylic
 polymers with narrow mol. weight distribution)

L23 ANSWER 4 OF 5 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER: 2004:965297 HCAPLUS
 DOCUMENT NUMBER: 141:411400
 TITLE: Process for production of living-radical
 polymers and polymers
 INVENTOR(S): Yamago, Shigeru; Yoshida, Junichi; Kameshima,
 Takashi
 PATENT ASSIGNEE(S): Otsuka Chemical Co., Ltd., Japan
 SOURCE: PCT Int. Appl., 51 pp.
 CODEN: PIXXD2
 DOCUMENT TYPE: Patent
 LANGUAGE: Japanese
 FAMILY ACC. NUM. COUNT: 1
 PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
WO 2004096870	A1	20041111	WO 2004-JP5989	20040426
W: AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NA, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW RW: BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW, AM, AZ, BY, KG, KZ, MD, RU, TJ, TM, AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IT, LU, MC, NL, PL, PT, RO, SE, SI, SK, TR, BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG				
EP 1619211	A1	20060125	EP 2004-729496	20040426
R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT, IE, SI, LT, LV, FI, RO, MK, CY, AL, TR, BG, CZ, EE, HU, PL, SK, HR				
CN 1780860	A	20060531	CN 2004-80011197	20040426
JP 3845109	B2	20061115	JP 2005-505899	20040426
US 2006199927	A1	20060907	US 2005-554242	20051025
PRIORITY APPLN. INFO.:			JP 2003-121223	A 20030425

WO 2004-JP5989

W

200404

26

OTHER SOURCE(S): MARPAT 141:411400

AB The polymers are prepared by polymerizing vinyl monomers by using an azo initiator, an organotellurium compound $R_1TeCR_2R_3R_4$ and a ditelluride compound $(R_1Te)_2$ [R_1 = C1-8 alkyl, (un)substituted aryl, aromatic heterocyclic group; R_2, R_3 = H, C1-8 alkyl; R_4 = (un)substituted aryl, aromatic heterocyclic group, acyl, oxycarbonyl, cyano]. Thus, 10 mmol Me methacrylate was polymerized in the presence of AIBN 0.10, dimethylditelluride 0.10, and 2-methyl-2-methyltellurylpropionitrile 0.10 mmol at 60° for 2 h to give 98% PMMA with Mn 9600 and Mw/Mn 1.15.

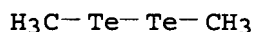
IT 20334-43-4P, Dimethylditelluride 77129-69-2P,
Dibutylditelluride 474094-06-9P 582319-76-4P
658058-35-6P

RL: CAT (Catalyst use); IMF (Industrial manufacture); PREP
(Preparation); USES (Uses)

(organotellurium catalysts for preparation of living-radical polymers)

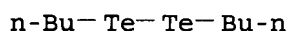
RN 20334-43-4 HCAPLUS

CN Ditelluride, dimethyl (9CI) (CA INDEX NAME)



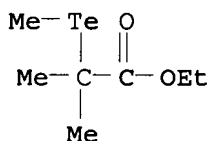
RN 77129-69-2 HCAPLUS

CN Ditelluride, dibutyl (CA INDEX NAME)



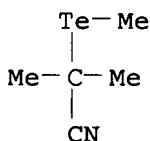
RN 474094-06-9 HCAPLUS

CN Propanoic acid, 2-methyl-2-(methyltelluro)-, ethyl ester (CA INDEX NAME)



RN 582319-76-4 HCAPLUS

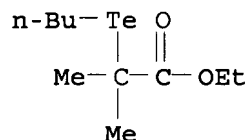
CN Propanenitrile, 2-methyl-2-(methyltelluro)- (CA INDEX NAME)



RN 658058-35-6 HCAPLUS

CN Propanoic acid, 2-(butyltelluro)-2-methyl-, ethyl ester (CA INDEX NAME)

NAME)



IC ICM C08F004-00
 CC 35-3 (Chemistry of Synthetic High Polymers)
 Section cross-reference(s): 29, 67
 IT 20334-43-4P, Dimethylditelluride 77129-69-2P,
 Dibutylditelluride 474094-06-9P 582319-76-4P
 658058-35-6P
 RL: CAT (Catalyst use); IMF (Industrial manufacture); PREP
 (Preparation); USES (Uses)
 (organotellurium catalysts for preparation of living-radical polymers)
 REFERENCE COUNT: 3 THERE ARE 3 CITED REFERENCES AVAILABLE FOR
 THIS RECORD. ALL CITATIONS AVAILABLE IN
 THE RE FORMAT

L23 ANSWER 5 OF 5 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER: 2004:143194 HCAPLUS

DOCUMENT NUMBER: 140:181982

TITLE: Process for production of living radical
polymers and block polymers

INVENTOR(S): Yamago, Shigeru; Yoshida, Junichi

PATENT ASSIGNEE(S): Otsuka Chemical Co., Ltd., Japan

SOURCE: PCT Int. Appl., 51 pp.

CODEN: PIXXD2

DOCUMENT TYPE: Patent

LANGUAGE: Japanese

FAMILY ACC. NUM. COUNT: 1

PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
WO 2004014962	A1	20040219	WO 2003-JP10116	20030808
W: AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NI, NO, NZ, OM, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW RW: GH, GM, KE, LS, MW, MZ, SD, SL, SZ, TZ, UG, ZM, ZW, AM, AZ, BY, KG, KZ, MD, RU, TJ, TM, AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IT, LU, MC, NL, PT, RO, SE, SI, SK, TR, BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG				
CA 2494983	A1	20040219	CA 2003-2494983	20030808
AU 2003254890	A1	20040225	AU 2003-254890	200308

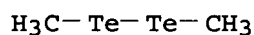
AU 2003254890	B2	20070823		08
EP 1541592	A1	20050615	EP 2003-784600	
				200308
				08
EP 1541592	B1	20070502		
R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC,				
PT, IE, SI, LT, LV, FI, RO, MK, CY, AL, TR, BG, CZ, EE, HU,				
SK				
CN 1675253	A	20050928	CN 2003-819158	
				200308
				08
RU 2285010	C2	20061010	RU 2005-106221	
				200308
				08
JP 3839829	B2	20061101	JP 2004-527371	
				200308
				08
AT 361322	T	20070515	AT 2003-784600	
				200308
				08
CN 101029117	A	20070905	CN 2007-10084346	
				200308
				08
US 2006167199	A1	20060727	US 2005-523611	
				200502
				07
JP 2006299278	A	20061102	JP 2006-172603	
				200606
				22
IN 2007DN06928	A	20070928	IN 2007-DN6928	
				200709
				07
PRIORITY APPLN. INFO.:			JP 2002-231917	A
				200208
				08
			CN 2003-819158	A3
				200308
				08
			JP 2004-527371	A3
				200308
				08
			WO 2003-JP10116	W
				200308
				08
			IN 2005-DN556	A3
				200502
				14

OTHER SOURCE(S): MARPAT 140:181982

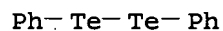
AB Vinyl monomers (e.g., MMA, styrene) are polymerized by using living radical polymerization initiators R1TeCR2R3R4 and (R1Te)2 [R1 = C1-8 alkyl, (un)substituted aryl, aromatic heterocyclic group; R2, R3 = H, C1-8 alkyl; R4 = (un)substituted aryl, aromatic heterocyclic group, acyl, oxycarbonyl, cyano]. The initiators enable precise control of mol. weight and mol.-weight distribution under mild conditions. Thus, poly(Me

methacrylate) (Mn 9000, Mw/Mn 1.18) was prepared by using (1-methyltelluranylethyl)benzene and di-Me ditelluride as initiators.

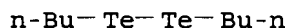
IT 20334-43-4P, Dimethyl ditelluride 32294-60-3P, Diphenyl ditelluride 77129-69-2P, Dibutyl ditelluride 415679-75-3P 474094-06-9P 658058-30-1P 658058-31-2P 658058-32-3P 658058-33-4P 658058-34-5P 658058-35-6P
 RL: CAT (Catalyst use); IMF (Industrial manufacture); PREP (Preparation); USES (Uses)
 (organotellurium compds. as living radical polymerization catalysts for preparation of polymers and block polymers)
 RN 20334-43-4 HCAPLUS
 CN Ditelluride, dimethyl (9CI) (CA INDEX NAME)



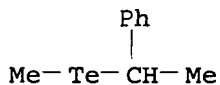
RN 32294-60-3 HCAPLUS
 CN Ditelluride, diphenyl (CA INDEX NAME)



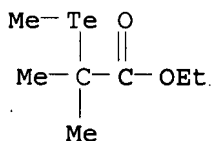
RN 77129-69-2 HCAPLUS
 CN Ditelluride, dibutyl (CA INDEX NAME)



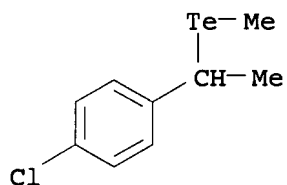
RN 415679-75-3 HCAPLUS
 CN Benzene, [1-(methyltelluro)ethyl]- (CA INDEX NAME)



RN 474094-06-9 HCAPLUS
 CN Propanoic acid, 2-methyl-2-(methyltelluro)-, ethyl ester (CA INDEX NAME)

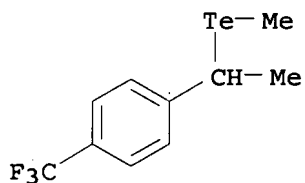


RN 658058-30-1 HCAPLUS
 CN Benzene, 1-chloro-4-[1-(methyltelluro)ethyl]- (CA INDEX NAME)



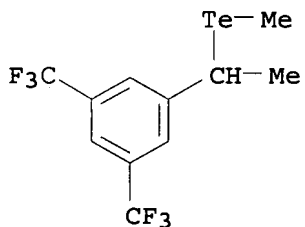
RN 658058-31-2 HCAPLUS

CN Benzene, 1-[1-(methyltelluro)ethyl]-4-(trifluoromethyl)- (CA INDEX NAME)



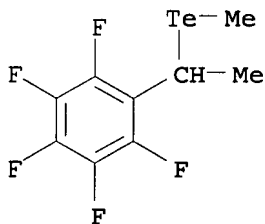
RN 658058-32-3 HCAPLUS

CN Benzene, 1-[1-(methyltelluro)ethyl]-3,5-bis(trifluoromethyl)- (CA INDEX NAME)



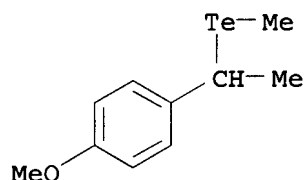
RN 658058-33-4 HCAPLUS

CN Benzene, pentafluoro[1-(methyltelluro)ethyl]- (9CI) (CA INDEX NAME)

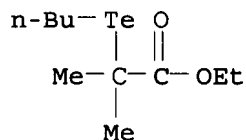


RN 658058-34-5 HCAPLUS

CN Benzene, 1-methoxy-4-[1-(methyltelluro)ethyl]- (CA INDEX NAME)



RN 658058-35-6 HCAPLUS
 CN Propanoic acid, 2-(butyltelluro)-2-methyl-, ethyl ester (CA INDEX NAME)



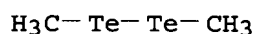
IC ICM C08F004-00
 ICS C08F297-00
 CC 35-3 (Chemistry of Synthetic High Polymers)
 Section cross-reference(s): 29, 67
 IT 20334-43-4P, Dimethyl ditelluride 32294-60-3P,
 Diphenyl ditelluride 77129-69-2P, Dibutyl ditelluride
 415679-75-3P 474094-06-9P 658058-30-1P
 658058-31-2P 658058-32-3P 658058-33-4P
 658058-34-5P 658058-35-6P
 RL: CAT (Catalyst use); IMF (Industrial manufacture); PREP
 (Preparation); USES (Uses)
 (organotellurium compds. as living radical polymerization catalysts for
 preparation of polymers and block polymers)
 REFERENCE COUNT: 2 THERE ARE 2 CITED REFERENCES AVAILABLE FOR
 THIS RECORD. ALL CITATIONS AVAILABLE IN
 THE RE FORMAT

=> d 129 ibib abs hitstr hitind 1-10

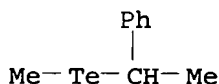
L29 ANSWER 1 OF 10 HCAPLUS COPYRIGHT 2007 ACS on STN
 ACCESSION NUMBER: 2007:177865 HCAPLUS
 DOCUMENT NUMBER: 146:422351
 TITLE: Kinetic Study on Role of Ditelluride in
 Organotellurium-Mediated Living Radical
 Polymerization (TERP)
 AUTHOR(S): Kwak, Yungwan; Tezuka, Miho; Goto, Atsushi;
 Fukuda, Takeshi; Yamago, Shigeru
 CORPORATE SOURCE: Institute for Chemical Research, Kyoto
 University, Uji, Kyoto, 611-0011, Japan
 SOURCE: Macromolecules (Washington, DC, United States)
 (2007), 40(6), 1881-1885
 CODEN: MAMOBX; ISSN: 0024-9297
 PUBLISHER: American Chemical Society
 DOCUMENT TYPE: Journal
 LANGUAGE: English
 AB The role of di-Me ditelluride (MeTe)₂ for the organotellurium-
 mediated living radical polymns. (TERPs) of styrene (St) and Me
 methacrylate (MMA) was kinetically studied. For both St and MMA,

there was a rapid reversible activation-deactivation process mediated by (MeTe)₂, i.e., P-TeMe + MeTe• \rightleftharpoons P• + (MeTe)₂: (MeTe)₂ worked as an efficient deactivator of the propagating radical P•, and the radical MeTe• worked as a highly reactive activator of the dormant species P-TeMe. This rapid reversible process accounted for the dramatic improvement of the polydispersity controllability with the addition of even a small amount of (MeTe)₂ for these polymers.

IT 20334-43-4, Dimethyl ditelluride
 RL: CAT (Catalyst use); PEP (Physical, engineering or chemical process); PROC (Process); USES (Uses)
 (kinetic study on role of ditelluride in organotellurium-mediated living radical polymerization)
 RN 20334-43-4 HCAPLUS
 CN Ditelluride, dimethyl (9CI) (CA INDEX NAME)



IT 415679-75-3
 RL: PRP (Properties)
 (model compound; kinetic study on role of ditelluride in organotellurium-mediated living radical polymerization)
 RN 415679-75-3 HCAPLUS
 CN Benzene, [1-(methyltelluro)ethyl]- (CA INDEX NAME)



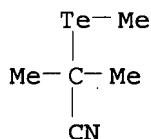
CC 35-3 (Chemistry of Synthetic High Polymers)
 IT Polymerization **catalysts**
 Polymerization kinetics
 (living, radical; kinetic study on role of ditelluride in organotellurium-mediated living radical polymerization)
 IT 20334-43-4, Dimethyl ditelluride
 RL: CAT (Catalyst use); PEP (Physical, engineering or chemical process); PROC (Process); USES (Uses)
 (kinetic study on role of ditelluride in organotellurium-mediated living radical polymerization)
 IT 415679-75-3
 RL: PRP (Properties)
 (model compound; kinetic study on role of ditelluride in organotellurium-mediated living radical polymerization)
 REFERENCE COUNT: 41 THERE ARE 41 CITED REFERENCES AVAILABLE FOR THIS RECORD. ALL CITATIONS AVAILABLE IN THE RE FORMAT

L29 ANSWER 2 OF 10 HCAPLUS COPYRIGHT 2007 ACS on STN
 ACCESSION NUMBER: 2004:986149 HCAPLUS
 DOCUMENT NUMBER: 141:411404
 TITLE: Manufacture of organotellurium compounds as living radical polymerization **initiators**
 INVENTOR(S): Yamako, Shigeru; Yoshida, Junichi; Kameshima, Takashi
 PATENT ASSIGNEE(S): Otsuka Chemical Co., Ltd., Japan
 SOURCE: Jpn. Kokai Tokkyo Koho, 10 pp.

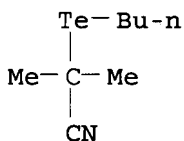
DOCUMENT TYPE: CODEN: JKXXAF
 LANGUAGE: Patent
 FAMILY ACC. NUM. COUNT: 1 Japanese
 PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
JP 2004323437	A	20041118	JP 2003-121825	20030425
PRIORITY APPLN. INFO.:			JP 2003-121825	20030425

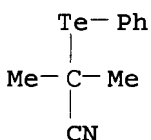
OTHER SOURCE(S): MARPAT 141:411404
 AB The compds. are manufactured by treatment of azo polymerization initiators with R1TeTeR2 (R1, R2 = C1-8 alkyl, aryl, heterocyclic group). Thus, AIBN was treated with MeTeTeMe to 17% give 2-methyl-2-methyltellanylpropionitrile.
 IT 582319-76-4P 791104-08-0P 791104-09-1P
 RL: CAT (Catalyst use); IMF (Industrial manufacture); PREP (Preparation); USES (Uses)
 (manufacture of organotellurium compds. as living radical polymerization initiators by treatment of azo polymerization initiators with ditellurides)
 RN 582319-76-4 HCAPLUS
 CN Propanenitrile, 2-methyl-2-(methyltelluro)- (CA INDEX NAME)



RN 791104-08-0 HCAPLUS
 CN Propanenitrile, 2-(butyltelluro)-2-methyl- (CA INDEX NAME)



RN 791104-09-1 HCAPLUS
 CN Propanenitrile, 2-methyl-2-(phenyltelluro)- (CA INDEX NAME)



IT 20334-43-4P, Dimethyl ditelluride 32294-60-3P,
Diphenyl ditelluride 77129-69-2P, Dibutyl ditelluride
RL: IMF (Industrial manufacture); RCT (Reactant); PREP
(Preparation); RACT (Reactant or reagent)
(manufacture of organotellurium compds. as living radical polymerization
initiators by treatment of azo polymerization initiators
with ditellurides)
RN 20334-43-4 HCAPLUS
CN Ditelluride, dimethyl (9CI) (CA INDEX NAME)

H₃C-Te-Te-CH₃

RN 32294-60-3 HCAPLUS
CN Ditelluride, diphenyl (CA INDEX NAME)

Ph-Te-Te-Ph

RN 77129-69-2 HCAPLUS
CN Ditelluride, dibutyl (CA INDEX NAME)

n-Bu-Te-Te-Bu-n

IC ICM C07C395-00
ICS C08F004-00
CC 35-3 (Chemistry of Synthetic High Polymers)
Section cross-reference(s): 23, 25
ST organotellurium living radical polymn initiator manuf; azo
polymn initiator ditelluride substitution; AIBN
dimethylditelluride substitution; methyl methyltellanyl
propionitrile polymn initiator manuf
IT Tellurides
RL: RCT (Reactant); RACT (Reactant or reagent)
(ditellurides, dialkyl; manufacture of organotellurium compds. as
living radical polymerization initiators by treatment of azo
polymerization initiators with ditellurides)
IT Polymerization catalysts
(living, radical; manufacture of organotellurium compds. as living
radical polymerization initiators by treatment of azo polymerization
initiators with ditellurides)
IT 109-72-8, Butyllithium, reactions 591-51-5, Phenyllithium
917-54-4
RL: RCT (Reactant); RACT (Reactant or reagent)
(ditelluride manufactured from; manufacture of organotellurium compds. as
living radical polymerization initiators by treatment of azo
polymerization initiators with ditellurides)
IT 582319-76-4P 791104-08-0P 791104-09-1P
RL: CAT (Catalyst use); IMF (Industrial manufacture); PREP
(Preparation); USES (Uses)
(manufacture of organotellurium compds. as living radical polymerization
initiators by treatment of azo polymerization initiators
with ditellurides)
IT 20334-43-4P, Dimethyl ditelluride 32294-60-3P,
Diphenyl ditelluride 77129-69-2P, Dibutyl ditelluride
RL: IMF (Industrial manufacture); RCT (Reactant); PREP

(Preparation); RACT (Reactant or reagent)
(manufacture of organotellurium compds. as living radical polymerization
initiators by treatment of azo polymerization initiators
with ditellurides)

IT 78-67-1, AIBN

RL: RCT (Reactant); RACT (Reactant or reagent)
(manufacture of organotellurium compds. as living radical polymerization
initiators by treatment of azo polymerization initiators
with ditellurides)

L29 ANSWER 3 OF 10 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER: 1994:164377 HCAPLUS

DOCUMENT NUMBER: 120:164377

TITLE: Synthesis of α -phenylchalcogeno acetic
acids, ethyl- α -phenylchalcogeno acetates
and ethyl- α -halo- α -phenylchalcogeno
acetates

AUTHOR(S): Dabdoub, Miguel J.; Guerrero, Palimecio G. Jr.;
Silveira, Claudio C.

CORPORATE SOURCE: Departamento de Quimica - F.F.C.L., Universidade
de Sao Paulo, Av. Bandeirantes, 3900, Ribeirao
Preto -SP, Brazil

SOURCE: Journal of Organometallic Chemistry (1993),
460(1), 31-7

CODEN: JORCAI; ISSN: 0022-328X

DOCUMENT TYPE: Journal

LANGUAGE: English

OTHER SOURCE(S): CASREACT 120:164377

AB Reaction of PhTe^- or PhSe^- anion with $\text{BrCH}_2\text{CO}_2\text{H}$ under phase-transfer
conditions in liquid-solid system affords the α -(phenyltelluro)-
and α -(phenylseleno)acetic acid in 44 and 50% yields, resp.
Under similar reaction conditions, Ph chalcogenate anions react with
 $\text{BrCH}_2\text{CO}_2\text{Et}$ give 52% $\text{PhTeCH}_2\text{CO}_2\text{Et}$ and 47% $\text{PhSeCH}_2\text{CO}_2\text{Et}$, resp.
Reaction of PhSeCl with $\text{N}_2\text{CHCO}_2\text{Et}$ (I) in THF at 0° yields
exclusively $\text{PhSeCHClCO}_2\text{Et}$ in 88% yield. Similar reactions by addition
of PhSeBr in THF or C_6H_6 to I at different temps. result in mixts.
of $\text{PhSeCHBrCO}_2\text{Et}$ (II) and $(\text{PhSe})_2\text{CHCO}_2\text{Et}$ in different ratios.
However, when the I was slowly added to a solution of PhSeBr in C_6H_6
under reflux, II was obtained in 84% yield as the only product.
Reaction of I with PhTeBr in C_6H_6 at room temperature results in formation
of $\text{PhTeCHBrCO}_2\text{Et}$ acetate that decomp. rapidly into the
corresponding tellurone. Addition of I to a mixture of Ph_2Se_2 and CuSO_4
in refluxing C_6H_6 results in a 10:1 $\text{PhSeCH}_2\text{CO}_2\text{Et}-(\text{PhSe})_2\text{CHCO}_2\text{Et}$
mixture. By an alternative route, the former was obtained in 74% yield
by esterification of $\text{PhSeCH}_2\text{CO}_2\text{H}$ in C_6H_6 with $\text{EtOH-H}_2\text{SO}_4$, and then
transformed into the α -bromo ester in 41% yield by treatment
with NBS. On the other hand, the Cu-catalyzed thermal reaction of I
with Ph_2Te_2 in C_6H_6 afforded $\text{PhTeCH}_2\text{CO}_2\text{Et}$ as the only product.

IT 32294-60-3, Diphenyl ditelluride

RL: RCT (Reactant); RACT (Reactant or reagent)
(condensation reaction of, with bromoacetic acid, phase
transfer-catalyzed)

RN 32294-60-3 HCAPLUS

CN Ditelluride, diphenyl (CA INDEX NAME)

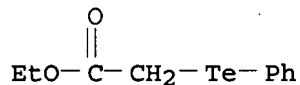
Ph-Te-Te-Ph

IT 116246-83-4P 127291-78-5P

RL: SPN (Synthetic preparation); PREP (Preparation)
(preparation of)

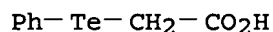
RN 116246-83-4 HCAPLUS

CN Acetic acid, (phenyltelluro)-, ethyl ester (9CI) (CA INDEX NAME)



RN 127291-78-5 HCAPLUS

CN Acetic acid, (phenyltelluro)- (9CI) (CA INDEX NAME)



CC 29-8 (Organometallic and Organometalloidal Compounds)

IT 112-02-7, Cetyltrimethylammonium chloride

RL: CAT (Catalyst use); USES (Uses)

(catalyst, for phase transfer-catalyzed reaction of
phenylchalcogenate anion with bromoacetate)

IT 1666-13-3, Diphenyl diselenide 32294-60-3, Diphenyl
ditelluride

RL: RCT (Reactant); RACT (Reactant or reagent)

(condensation reaction of, with bromoacetic acid, phase
transfer-catalyzed)

IT 72041-41-9P 116246-83-4P 127291-78-5P

138100-77-3P 142753-40-0P 153490-06-3P

RL: SPN (Synthetic preparation); PREP (Preparation)
(preparation of)

L29 ANSWER 4 OF 10 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER: 1992:59144 HCAPLUS

DOCUMENT NUMBER: 116:59144

TITLE: Novel preparation of highly electrophilic
species for benzenetellurenylation or
benzenesulfonylation by nitrobenzenesulfonyl
peroxide in combination with ditelluride or
disulfide. Application to intramolecular ring
closures

AUTHOR(S): Yoshida, Masato; Suzuki, Takashi; Kamigata,
Nobumasa

CORPORATE SOURCE: Fac. Sci., Tokyo Metrop. Univ., Hachioji,
192-03, Japan

SOURCE: Journal of Organic Chemistry (1992), 57(1),
383-6

CODEN: JOCEAH; ISSN: 0022-3263

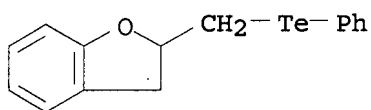
DOCUMENT TYPE: Journal

LANGUAGE: English

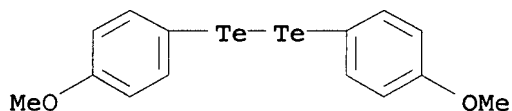
OTHER SOURCE(S): CASREACT 116:59144

AB Electrophilic intramol. ring closures of unsatd. hydroxy or carboxy
compds. were effected by nitrobenzenesulfonyl peroxide (I) in
combination with PhTe₂Ph (II) or PhS₂Ph (III). Upon treatment with
I, II was converted into an electrophilic species, which acted as an
initiator for the cyclization of unsatd. alcs. to afford
cyclic ethers. On the other hand, the electrophilic benzene
sulfonyl species, similarly prepared from I and III could be used for
phenylsulfolactonizations of unsatd. carboxylic acids.

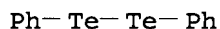
IT 122823-57-8P
 RL: SPN (Synthetic preparation); PREP (Preparation)
 (preparation of)
 RN 122823-57-8 HCAPLUS
 CN Benzofuran, 2,3-dihydro-2-[(phenyltelluro)methyl]- (9CI) (CA INDEX NAME)



IT 35684-37-8
 RL: RCT (Reactant); RACT (Reactant or reagent)
 (reaction of, with nitrobenzenesulfonyl peroxide)
 RN 35684-37-8 HCAPLUS
 CN Ditelluride, bis(4-methoxyphenyl) (9CI) (CA INDEX NAME)



IT 32294-60-3, Diphenyl ditelluride
 RL: RCT (Reactant); RACT (Reactant or reagent)
 (reaction of, with nitrobenzenesulfonyl peroxide)
 RN 32294-60-3 HCAPLUS
 CN Ditelluride, diphenyl (CA INDEX NAME)



CC 27-13 (Heterocyclic Compounds (One Hetero Atom))
 IT 108078-64-4P 108078-67-7P 113345-02-1P 122823-50-1P
 122823-57-8P 137542-98-4P 137542-99-5P 137543-00-1P
 RL: SPN (Synthetic preparation); PREP (Preparation)
 (preparation of)
 IT 35684-37-8
 RL: RCT (Reactant); RACT (Reactant or reagent)
 (reaction of, with nitrobenzenesulfonyl peroxide)
 IT 882-33-7, Diphenyl disulfide 32294-60-3, Diphenyl ditelluride
 RL: RCT (Reactant); RACT (Reactant or reagent)
 (reaction of, with nitrobenzenesulfonyl peroxide)

L29 ANSWER 5 OF 10 HCAPLUS COPYRIGHT 2007 ACS on STN
 ACCESSION NUMBER: 1991:513992 HCAPLUS
 DOCUMENT NUMBER: 115:113992
 TITLE: Synthesis of alkali metal tellurides and ditellurides in THF and their relative reactivities towards alkyl bromides: a convenient synthesis of dialkyl tellurides and dialkyl ditellurides
 AUTHOR(S): Bhasin, K. K.; Gupta, Vijay; Sharma, R. P.
 CORPORATE SOURCE: Dep. Chem., Panjab Univ., Chandigarh, 160 014,

India
SOURCE: Indian Journal of Chemistry, Section A:
Inorganic, Bio-inorganic, Physical, Theoretical
& Analytical Chemistry (1991), 30A(7), 632-4
CODEN: ICACEC; ISSN: 0376-4710
DOCUMENT TYPE: Journal
LANGUAGE: English
OTHER SOURCE(S): CASREACT 115:113992
AB Lithium, sodium and potassium reduce smoothly elemental tellurium to
telluride (Te²⁻) and ditelluride (Te₂²⁻) anions in THF in the
presence of catalytic amts. of naphthalene. The relative
reactivities of these alkali metal tellurides towards alkyl bromides
have been investigated and a number of dialkyl tellurides, e.g., Bu₂Te
and dialkyl ditellurides were prepared in good to excellent yields.
IT 20727-11-1P 26105-63-5P 62654-03-9P
77129-69-2P 131443-43-1P 135764-72-6P
RL: SPN (Synthetic preparation); PREP (Preparation)
(preparation of)
RN 20727-11-1 HCAPLUS
CN Ditelluride, bis(phenylmethyl) (CA INDEX NAME)

Ph-CH₂-Te-Te-CH₂-Ph

RN 26105-63-5 HCAPLUS
CN Ditelluride, diethyl (CA INDEX NAME)

Et-Te-Te-Et

RN 62654-03-9 HCAPLUS
CN Benzene, 1,1'-[tellurobis(methylene)]bis- (9CI) (CA INDEX NAME)

Ph-CH₂-Te-CH₂-Ph

RN 77129-69-2 HCAPLUS
CN Ditelluride, dibutyl (CA INDEX NAME)

n-Bu-Te-Te-Bu-n

RN 131443-43-1 HCAPLUS
CN Ditelluride, bis(2-methoxyethyl) (9CI) (CA INDEX NAME)

MeO-CH₂-CH₂-Te-Te-CH₂-CH₂-OMe

RN 135764-72-6 HCAPLUS
CN Ditelluride, bis(2-ethoxyethyl) (9CI) (CA INDEX NAME)

EtO-CH₂-CH₂-Te-Te-CH₂-CH₂-OEt

CC 23-13 (Aliphatic Compounds)
Section cross-reference(s): 78

IT 91-20-3, Naphthalene, uses and miscellaneous
RL: CAT (Catalyst use); USES (Uses)
(catalysts, for reaction of tellurium with alkali metals)

IT 627-54-3P 20727-11-1P 26105-63-5P 38788-38-4P
62654-03-9P 77129-69-2P 131443-42-0P
131443-43-1P 135764-71-5P 135764-72-6P
RL: SPN (Synthetic preparation); PREP (Preparation)
(preparation of)

L29 ANSWER 6 OF 10 HCAPLUS COPYRIGHT 2007 ACS on STN
ACCESSION NUMBER: 1989:423137 HCAPLUS
DOCUMENT NUMBER: 111:23137
TITLE: Catalytic oxidation of olefins using diphenyl ditelluride
AUTHOR(S): Kambe, Nobuaki; Fujioka, Toyozo; Ogawa, Akiya; Miyoshi, Noritaka; Sonoda, Noboru
CORPORATE SOURCE: Fac. Eng., Osaka Univ., Suita, 565, Japan
SOURCE: Phosphorus and Sulfur and the Related Elements (1988), Volume Date 1987, 38(1-2), 167-75
CODEN: PREEDF; ISSN: 0308-664X
DOCUMENT TYPE: Journal
LANGUAGE: English
OTHER SOURCE(S): CASREACT 111:23137

AB Reaction of aliphatic alkenes (e.g., 1-octene) with Me₃COOH and PhTeTePh in MeOH containing H₂SO₄ gave methoxytellurenylation products [e.g., H(CH₂)₆CH(OMe)CH₂TePh] regioselectively. Cyclohexene gave only trans-1-methoxy-2-(phenyltelluro)cyclohexane. Under similar conditions, aromatic alkenes (e.g., p-MeC₆H₄CH:CH₂) gave dimethoxy derivs. [e.g., p-MeC₆H₄CH(OMe)CH₂OMe]. Other oxidants (O, H₂O₂, m-ClC₆H₄CO₂OH) were also effective. The mechanism is discussed.

IT 32294-60-3, Diphenyl ditelluride
RL: CAT (Catalyst use); USES (Uses)
(catalyst, for oxidation of alkenes with Bu hydroperoxide-methanol)

RN 32294-60-3 HCAPLUS
CN Ditelluride, diphenyl (CA INDEX NAME)

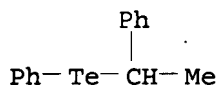
Ph-Te-Te-Ph

IT 32344-00-6P 121335-32-8P
RL: RCT (Reactant); SPN (Synthetic preparation); PREP (Preparation); RACT (Reactant or reagent)
(preparation and methoxylation of)

RN 32344-00-6 HCAPLUS
CN Benzene, [(phenylmethyl)telluro]- (CA INDEX NAME)

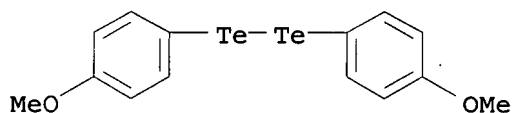
Ph-CH₂-Te-Ph

RN 121335-32-8 HCAPLUS
CN Benzene, [(1-phenylethyl)telluro]- (CA INDEX NAME)

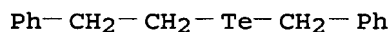


CC 25-9 (Benzene, Its Derivatives, and Condensed Benzenoid Compounds)
 ST alkene aliph methoxytellurenylation regiochem; arom alkene
 methoxylation ditelluride **catalyst**; phenyltelluroalkane
 methoxy; oxidn arylalkene hydroperoxide methanol
 IT Methoxylation **catalysts**
 (di-Ph ditelluride, for aromatic alkenes with Bu
 hydroperoxide-methanol)
 IT 32294-60-3, Diphenyl ditelluride
 RL: CAT (Catalyst use); USES (Uses)
 (**catalyst**, for oxidation of alkenes with Bu
 hydroperoxide-methanol)
 IT 32344-00-6P 121335-32-8P
 RL: RCT (Reactant); SPN (Synthetic preparation); PREP (Preparation);
 RACT (Reactant or reagent)
 (preparation and methoxylation of)

L29 ANSWER 7 OF 10 HCAPLUS COPYRIGHT 2007 ACS on STN
 ACCESSION NUMBER: 1989:406962 HCAPLUS
 DOCUMENT NUMBER: 111:6962
 TITLE: A new and efficient reaction for the synthesis
 of the carbon-carbon bond
 AUTHOR(S): Barton, Derek H. R.; Ozbalik, Nubar; Ramesh,
 Manian
 CORPORATE SOURCE: Dep. Chem., Texas A and M Univ., College
 Station, TX, 77843, USA
 SOURCE: Tetrahedron Letters (1988), 29(29), 3533-6
 CODEN: TELEAY; ISSN: 0040-4039
 DOCUMENT TYPE: Journal
 LANGUAGE: English
 OTHER SOURCE(S): CASREACT 111:6962
 AB Sym. and unsym. tellurides R₁TeR₂ (R₁ = anisyl, PLCH₂CH₂; R₂ =
 anisyl, PhCH₂CH₂, PhCH₂, 1-adamantyl, C₁₅H₃₁) were treated with Pd
 in MeCN to give the resp. R₁R₂; cross-coupling was not observed
 Similarly, dianisyl ditelluride was converted to MeOC₆H₄C₆H₄OMe.
 IT 35684-37-8 119784-58-6, Benzyl phenethyl telluride
 RL: RCT (Reactant); RACT (Reactant or reagent)
 (demetalation of, **catalysts** for)
 RN 35684-37-8 HCAPLUS
 CN Ditelluride, bis(4-methoxyphenyl) (9CI) (CA INDEX NAME)



RN 119784-58-6 HCAPLUS
 CN Benzene, [[[2-phenylethyl)telluro]methyl]- (9CI) (CA INDEX NAME)



CC 25-2 (Benzene, Its Derivatives, and Condensed Benzenoid Compounds)
Section cross-reference(s): 23, 24, 29

ST demetalation aryl telluride **catalyst**; biphenyl; alkyl
telluride demetalation **catalyst**; adamantyl telluride
demetalation **catalyst**

IT Tellurides
RL: RCT (Reactant); RACT (Reactant or reagent)
(demetalation of, **catalysts** for)

IT Substitution reaction **catalysts**
(tellurylation, retro, palladium, for aryl and arylalkyl
tellurides)

IT 7440-05-3, Palladium, uses and miscellaneous
RL: CAT (Catalyst use); USES (Uses)
(**catalysts**, for demetalation of aryl and arylalkyl
tellurides)

IT 4456-34-2 **35684-37-8** 71766-40-0, Diphenethyl telluride
95177-44-9 **119784-58-6**, Benzyl phenethyl telluride
119784-59-7
RL: RCT (Reactant); RACT (Reactant or reagent)
(demetalation of, **catalysts** for)

L29 ANSWER 8 OF 10 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER: 1985:184440 HCAPLUS

DOCUMENT NUMBER: 102:184440

TITLE: Organotelluriums. V. Nucleophilic cleavages of
esters and ethers with
phenyltellurotrimethylsilane

AUTHOR(S): Sasaki, Kazuaki; Aso, Yoshio; Otsubo, Tetsuo;
Ogura, Fumio

CORPORATE SOURCE: Fac. Eng., Hiroshima Univ., Higashi-Hiroshima,
724, Japan

SOURCE: Tetrahedron Letters (1985), 26(4), 453-6
CODEN: TELEAY; ISSN: 0040-4039

DOCUMENT TYPE: Journal

LANGUAGE: English

OTHER SOURCE(S): CASREACT 102:184440

AB Treatment of esters and ethers with PhTeSiMe₃ in the presence of
ZnI₂ **catalyst** under very mild conditions gave
C-telluration and O-silylation products via nucleophilic cleavages
of the C-O bonds. Thus, cleavage of butyrolactone gave
PhTe(CH₂)₃CO₂H and that of methyloxirane gave PhTeCH₂CHMeOSiMe₃.

IT **32344-00-6P**
RL: SPN (Synthetic preparation); PREP (Preparation)
(preparation of)

RN 32344-00-6 HCAPLUS

CN Benzene, [(phenylmethyl)telluro]- (CA INDEX NAME)

Ph-CH₂-Te-Ph

IT **32294-60-3**
RL: RCT (Reactant); RACT (Reactant or reagent)
(reaction of, with sodium and trimethylsilyl chloride)

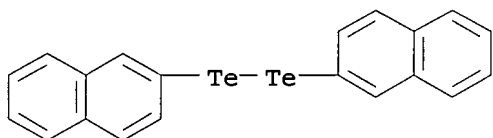
RN 32294-60-3 HCAPLUS

CN Ditelluride, diphenyl (CA INDEX NAME)

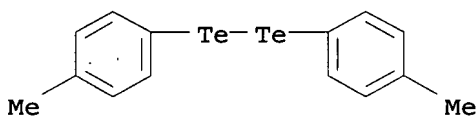
Ph-Te-Te-Ph

CC 21-2 (General Organic Chemistry)
 IT 872-89-9P 1529-17-5P 1825-61-2P 6221-88-1P 14642-79-6P
 32343-98-9P 32344-00-6P 91489-38-2P 96185-49-8P
 96185-50-1P 96185-51-2P 96185-52-3P 96185-53-4P 96185-54-5P
 96185-55-6P 96185-56-7P 96185-57-8P 96185-58-9P 96206-05-2P
 RL: SPN (Synthetic preparation); PREP (Preparation)
 (preparation of)
 IT 32294-60-3
 RL: RCT (Reactant); RACT (Reactant or reagent)
 (reaction of, with sodium and trimethylsilyl chloride)

L29 ANSWER 9 OF 10 HCAPLUS COPYRIGHT 2007 ACS on STN
 ACCESSION NUMBER: 1985:166398 HCAPLUS
 DOCUMENT NUMBER: 102:166398
 TITLE: Alkaline hydrolysis of diaryl ditellurides under
 phase transfer conditions; synthesis of alkyl
 aryl tellurides
 AUTHOR(S): Comasseto, J. V.; Ferreira, J. T. B.; Val, J. A.
 Fontanillas
 CORPORATE SOURCE: Inst. Quim., Univ. Sao Paulo, Sao Paulo, Brazil
 SOURCE: Journal of Organometallic Chemistry (1984),
 277(2), 261-6
 CODEN: JORCAI; ISSN: 0022-328X
 DOCUMENT TYPE: Journal
 LANGUAGE: English
 OTHER SOURCE(S): CASREACT 102:166398
 AB The disproportionation reaction of RTeTeR (R = Ph, 4-MeC₆H₄,
 4-MeOC₆H₄, 4-EtOC₆H₄, 2-naphthyl) with NaOH under phase transfer
 conditions at room temperature is carried out with 2HT-75, a mixture of
 dialkyldimethylammonium chlorides. The intermediates aryl
 tellurolates react in situ with alkyl halides to give 52-72% alkyl
 aryl tellurides RTeR₁ (R₁ = Bu, CH₂CH₂CHMe₂, CH₂CHMe₂, CH₂CH₂CHMeBr,
 decyl, CH₂Ph, CH₂Cl, CH₂CH₂Ph, allyl, CH₂CH:CHPh, CH₂SePh,
 2-cyclohexen-1-yl).
 IT 1666-12-2 32294-57-8 32294-60-3
 35684-37-8 35684-38-9
 RL: RCT (Reactant); RACT (Reactant or reagent)
 (disproportionation reactions of, phase transfer catalysis in)
 RN 1666-12-2 HCAPLUS
 CN Ditelluride, di-2-naphthalenyl (CA INDEX NAME)



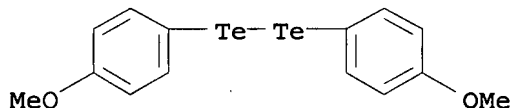
RN 32294-57-8 HCAPLUS
 CN Ditelluride, bis(4-methylphenyl) (CA INDEX NAME)



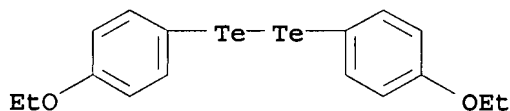
RN 32294-60-3 HCAPLUS
 CN Ditelluride, diphenyl (CA INDEX NAME)



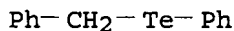
RN 35684-37-8 HCAPLUS
 CN Ditelluride, bis(4-methoxyphenyl) (9CI) (CA INDEX NAME)



RN 35684-38-9 HCAPLUS
 CN Ditelluride, bis(4-ethoxyphenyl) (9CI) (CA INDEX NAME)



IT 32344-00-6P
 RL: SPN (Synthetic preparation); PREP (Preparation)
 (preparation of)
 RN 32344-00-6 HCAPLUS
 CN Benzene, [(phenylmethyl)telluro]- (CA INDEX NAME)



CC 25-14 (Benzene, Its Derivatives, and Condensed Benzenoid Compounds)
 IT Disproportionation **catalysts**
 (phase-transfer, for diarylditellurides)

IT 1666-12-2 32294-57-8 32294-60-3
 35684-37-8 35684-38-9

RL: RCT (Reactant); RACT (Reactant or reagent)
 (disproportionation reactions of, phase transfer catalysis in)

IT 32343-98-9P 32344-00-6P 55136-86-2P 55136-87-3P
 56950-02-8P 81609-30-5P 83817-36-1P 87550-08-1P 95849-63-1P
 95849-64-2P 95849-65-3P 95849-66-4P 95849-67-5P 95849-68-6P
 95849-69-7P 95849-70-0P

RL: SPN (Synthetic preparation); PREP (Preparation)
 (preparation of)

L29 ANSWER 10 OF 10 HCAPLUS COPYRIGHT 2007 ACS on STN

ACCESSION NUMBER: 1979:532159 HCAPLUS

DOCUMENT NUMBER: 91:132159

TITLE: Organotellurium (II) and (IV) compounds in
 heat-developable imaging materials and process
 with physically-developable nuclei

INVENTOR(S): Lelental, Mark; Gysling, Henry J.

PATENT ASSIGNEE(S): Eastman Kodak Co., USA

SOURCE: U.S., 12 pp.

DOCUMENT TYPE: CODEN: USXXAM
 LANGUAGE: Patent
 FAMILY ACC. NUM. COUNT: English 3
 PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
US 4152155	A	19790501	US 1977-848063	19771103
CA 1081949	A1	19800722	CA 1976-259885	19760826
FR 2357932	A1	19780203	FR 1977-20874	19770707
FR 2357932	B1	19790427		
JP 53007226	A	19780123	JP 1977-81119	19770708
GB 1580073	A	19801126	GB 1977-28794	19770708
US 4144062	A	19790313	US 1977-848062	19771103
PRIORITY APPLN. INFO.:			US 1976-703477	A2 19760708

AB An imaging composition containing a Te(II) or Te(IV) compound as an oxidizing agent and a reducing agent is described. The composition, which is especially useful in heat-developable materials containing sources of phys. developable nuclei, provides an improved amplified image by heating the element to moderately elevated temps. Thus, a paper support was coated at 9 mils (wet) with a solution prepared by mixing a 10% solution of 2-hydroxy-5-methyl-3-piperidino-2-cyclopentenone in Me₂CO-PhMe-DMF (45:45:10) 2 mL and a 2% solution of poly(vinyl butyral) 10 mL containing Te[S₂CN(Et₂)₂] 40 mg. The resulting heat-developable material was then laminated in face-to-face contact with a step tablet distribution of Ag nuclei, vapor deposited on a poly(ethylene terephthalate) film support. The resulting so-called sandwich was then passed between heated rollers at 175° to provide heating at this temperature for 15 s. This produced dark Te deposits of neutral (black) tone in the areas in which the Ag nuclei and the layer containing the Te complex were adjacent.

IT 32294-60-3 62654-04-0

RL: USES (Uses)

(photosensitive compns. containing, for heat-developable photoimaging materials for use with phys. developable nuclei)

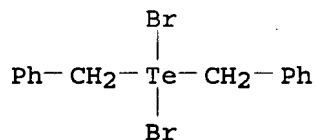
RN 32294-60-3 HCAPLUS

CN Ditelluride, diphenyl (CA INDEX NAME)

Ph-Te-Te-Ph

RN 62654-04-0 HCAPLUS

CN Tellurium, dibromobis(phenylmethyl)-, (T-4)- (9CI) (CA INDEX NAME)



IC G03C005-24; G03C001-76; G03C001-00; G03C001-02

INCL 096048000PD

CC 74-8 (Radiation Chemistry, Photochemistry, and Photographic Processes)

IT 7440-05-3, uses and miscellaneous 7440-22-4, uses and miscellaneous 7440-50-8, uses and miscellaneous 7440-57-5, uses and miscellaneous

RL: CAT (Catalyst use); USES (Uses)

(catalysts, for use with photosensitive photoimaging compns. containing organotellurium compound)

IT 50-81-7, uses and miscellaneous 92-43-3 119-47-1 837-13-8

1838-13-7 1948-33-0 2049-55-0 2654-58-2 5471-90-9

5930-28-9 6112-49-8 13047-13-7 15080-52-1 32294-60-3

41756-91-6 51767-45-4 62654-04-0 66083-69-0

66084-81-9 66084-84-2 66101-97-1 71210-34-9

RL: USES (Uses)

(photosensitive compns. containing, for heat-developable photoimaging materials for use with phys. developable nuclei)

=>